

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Woody Tang, et. al
Assignee: Mosel Vitelic, Inc.
Title: Methods of Reducing or Removing Micromasking Residue Prior to Metal Etch Using Oxide Hardmask
Application No.: 10/649,099 Filing Date: 08/26/2003
Examiner: Dahimene, Mahmoud Group Art Unit: 1765
Docket No.: M-12977 US Confirm: 4957

San Jose, California
June 3, 2008

VIA EFS-WEB
COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE

**Including Submission of Declarations and Other Evidence Pursuant to
37 CFR 1.131 for Antedating a Reference**

Dear Sir:

The nonfinal Office Action of 3/03/2008 consisted of obviousness rejections all predicated on Doshita US 2003/0235987 A1 which published 12/25/2003 (which is after the 8/26/2003 filing date of the present application) based on a US filing date of 6/20/2003.

Applicants hereby antedate the effective date of the Doshita reference by demonstrating a date of invention prior to 6/20/2008. Withdrawal of the outstanding rejections is respectfully requested based on this submission.

REMARKS

Enclosed herewith are the declarations of inventor George Kovall and non-inventor/witness Harki Singh as well as Exhibits A, B and C (with dates thereon redacted).

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